

# UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/563,115	01/03/2006	Masaki Mizutani	03500.109446	1106
5514 7590 06/26/2007 FITZPATRICK CELLA HARPER & SCINTO 30 ROCKEFELLER PLAZA NEW YORK, NY 10112			EXAMINER	
			HITESHEW, FELISA CARLA	
NEW YORK,	NY 10112		ART UNIT	PAPER NUMBER
			1722	
			<u></u>	
			MAIL DATE	DELIVERY MODE
			06/26/2007	PAPĖR

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

	Application No.	Applicant(s)			
Office Anti-on Occurrence	10/563,115	MIZUTANI ET AL.			
Office Action Summary	Examiner	Art Unit			
	Felisa C. Hiteshew	1722			
The MAILING DATE of this communication ap Period for Reply	pears on the cover sheet with the c	correspondence address			
A SHORTENED STATUTORY PERIOD FOR REPL WHICHEVER IS LONGER, FROM THE MAILING ID.  - Extensions of time may be available under the provisions of 37 CFR 1. after SIX (6) MONTHS from the mailing date of this communication.  - If NO period for reply is specified above, the maximum statutory period.  - Failure to reply within the set or extended period for reply will, by statut Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNICATION  .136(a). In no event, however, may a reply be tire  I will apply and will expire SIX (6) MONTHS from the, cause the application to become ABANDONE	N. nely filed the mailing date of this communication. (D. (35 U.S.C. § 133).			
Status		•			
1) Responsive to communication(s) filed on 2a) This action is <b>FINAL</b> . 2b) Thi 3) Since this application is in condition for alloware closed in accordance with the practice under	s action is non-final. ance except for formal matters, pro				
Disposition of Claims					
4) ☐ Claim(s) 1-4 is/are pending in the application. 4a) Of the above claim(s) is/are withdra 5) ☐ Claim(s) 1-3 is/are allowed. 6) ☐ Claim(s) 4 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and/or a subject to by the Examination of the drawing(s) filed on is/are: a) ☐ according to a subject to by the Examination of the drawing(s) filed on is/are: a) ☐ according to a subject to by the Examination of the drawing(s) filed on is/are: a) ☐ according to a subject to a subject to by the Examination of the drawing(s) filed on is/are: a) ☐ according to a subject to a subject to by the Examination of the drawing(s) filed on is/are: a) ☐ according to a subject to a subject to a subject to a subject to by the Examination of the drawing to a subject to a	or election requirement.	Examiner			
Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the E	e drawing(s) be held in abeyance. Section is required if the drawing(s) is ob	e 37 CFR 1.85(a). jected to. See 37 CFR 1.121(d).			
Priority under 35 U.S.C. § 119					
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).  a) All b) Some * c) None of:  1. Certified copies of the priority documents have been received.  2. Certified copies of the priority documents have been received in Application No  3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).  * See the attached detailed Office action for a list of the certified copies not received.					
A440.h.m.o.u4/o.\					
Attachment(s)  1) Notice of References Cited (PTO-892)  2) Notice of Draftsperson's Patent Drawing Review (PTO-948)  3) Information Disclosure Statement(s) (PTO/SB/08)  Paper No(s)/Mail Date See Continuation Sheet.	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:	ate			

Continuation of Attachment(s) 3). Information Disclosure Statement(s) (PTO/SB/08), Paper No(s)/Mail Date :5/1/2007; 7/10/2006 & 5/12/2006.

## **Priority**

1. Receipt is acknowledged of papers submitted under 35 U.S.C. 119(a)-(d), which papers have been placed of record in the file.

#### Information Disclosure Statement

The Information Disclosure Statement under 37 C.F.R. 1.97 has been received and reviewed. However, the information disclosure is not deemed to be pertinent over the prior art of record.

### Claim Rejections - 35 USC § 112

- 2. Claim 4 recites the limitation "...the step of etching..." in line 4. There is insufficient antecedent basis for this limitation in the claim. Please delete the word "the" (first occurrence) and insert the word -- a -- for proper antecedence.
- 3. Claim 4 recites the limitation "...the range of ..." in line 6. There is insufficient antecedent basis for this limitation in the claim. Please delete the word "the" and insert the word -- a -- for proper antecedence.

## Allowable Subject Matter

- 4. Claims 1-3 are allowed.
- 5. As allowable subject matter has been indicated, applicant's reply must either comply with all formal requirements or specifically traverse each requirement not complied with. See 37 CFR 1.111(b) and MPEP § 707.07(a).
- 6. The following is an examiner's statement of reasons for allowance: The most relevant prior art of record was that which was submitted by the applicants. However, they do not teach nor fairly suggest singularly or in any combination thereof a silicon

Application/Control Number: 10/563,115 Page 3

Art Unit: 1722

layer growth method comprising dipping a multicrystalline silicon substrate in a solution comprising silicon and lowering the temperature of the solution, to thereby grow a silicon layer on the substrate, wherein the temperature is monotonic decreasing and the temperature drop rate of the solution during the dipping of the substrate in the solution is decreased with time.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

FELISA HITESHEW PRIMARY EXAMINER

AU 1722